| Notice of Allowability | Application No. | Applicant(s) | |
|--|---|--|----------------|
| | 10/016,089 | DENZINGER ET AL. | |
| | Examiner | Art Unit | |
| | John S. Chu | 1752 | |
| The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313 | (OR REMAINS) CLOSED in this or other appropriate communicat GHTS. This application is subjection. | application. If not included ion will be mailed in due course. The | IIS tiative |
| 1. This communication is responsive to <u>12/27/04</u> . | | | |
| 2. The allowed claim(s) is/are <u>18-37</u> . | | | |
| 3. The drawings filed on are accepted by the Examine | ri. | | |
| 4. | been received. been received in Application No. cuments have been received in the of this communication to file a rep ENT of this application. itted. Note the attached EXAMINE as reason(s) why the oath or decla t be submitted. on's Patent Drawing Review (PT Amendment / Comment or in the state of BIOLOGICAL MATERIAL | is national stage application from the place of the place | ı |
| Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/03 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material | 6. ☐ Interview Summa Paper No./Mail [8), 7. ☐ Examiner's Amen | Date | |
| | | John S. Chu Primary Examiner Art Unit: 1752 | |

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REASONS FOR ALLOWANCE

- 1. The following is an examiner's statement of reasons for allowance: The claimed invention is drawn to the following:
 - 18. (Previously presented) A recording material for the production of offset printing plates, which comprises a web- or plate-form support, a radiation-sensitive layer on the front of the support and a continuous, pigment particle-free layer on the back, and the back layer consists essentially of an organic polymeric material having a glass transition temperature Tg of at least 45°C, and said material has a surface and said surface has a Bekk smoothness of from 5 to 800 s.

None of the references of record anticipate or render obvious the claimed invention.

Newly cited reference to DENZINGER et al (2002/0182533) claims a similar backing layer, wherein the recited glass transition temperature range of at least 55 °C is within the range of the claimed Tg of the backing layer. However the claims require a conductive pigment which is excluded in the current claim 18 and thus the currently claimed recording material would not possess the claimed surface resistance of DENZINGER '533 because it lacks the conductive pigment as claimed. Further the filing date to the U.S. Patent Publication is March 1, 2002 which is after the current filing date of December 13, 2001 and does not qualify as prior art.

Because of the reasons stated above and because of the arguments by applicant against NARUSE et al (EP 883,028) are persuasive, claims 18-37 are seen as allowable and passed to issue.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

2. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The

examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

The fax phone number for the USPTO is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the Group receptionist whose telephone number is (571) 272-1700.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PMR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

John S. Chu

Primary Examiner, Group 1700

J.Chu April 4, 2005